

Title (en)

MICROREPLICATION OF TRANSITORY-IMAGE RELIEF PATTERN BASED OPTICALLY VARIABLE DEVICES

Title (de)

MIKROABFORMUNG VON OPTISCH VARIABLEN VORRICHTUNGEN AUF DER BASIS EINES TRANSIENTBILDRELIEFMUSTERS

Title (fr)

MICROREPLICATION DE DISPOSITIFS A VARIABILITE OPTIQUE BASES SUR DES MOTIFS EN RELIEF A IMAGE TRANSITOIRE

Publication

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Application

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Abstract (en)

[origin: WO2005074358A2] The invention concerns a method for the replication by hot-embossing, hot-stamping or plastic injection moulding of an optically variable transitory image relief pattern characterized by the use of a Silicon origination shim fabricated through a micromachining process. The invention also comprises objects and structures obtained according to said method.

IPC 8 full level

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Citation (search report)

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